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A CMOS Delay Locked Loop and Sub-Nanosecond Time-to-Digital Converter Chip

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Abstract

Many high energy physics and nuclear science applications require sub-nanosecond time resolution measurements over many thousands of detector channels. Phase-locked loops have been employed in the past to obtain accurate time references for these measurements. An alternative solution, based on a delay-locked loop (DLL) is described. This solution allows for a very high level of integration yet still offers resolution in the sub-nanosecond regime. Two variations on this solution are outlined. A novel phase detector, based on the Muller C element, is used to implement a charge pump where the injected charge approaches zero as the loop approaches lock on the leading edge of an input clock reference. This greatly reduces timing jitter. In the second variation the loop locks to both the leading and trailing clock edges. In this second implementation, software coded layout generators are used to automatically layout a highly integrated, multi-channel, time to digital converter (TDC). Complex clock generation can be achieved by taking symmetric taps off the delay elements. The two circuits, DLL and TDC, were implemented in a CMOS 1.2 μ m and 0.8 μ m technology, respectively. Test results show a timing jitter of less than 35 ps for the DLL circuit and better than 135 ps resolution for the TDC circuit.

I. INTRODUCTION

The generation of precise time delays with very low time jitter is useful in many time measurement applications in nuclear and high energy physics. Most solutions use phase-locked-loops (PLL). Delay-locked loops (DLL's) may, however, be preferable due to their inherently better stability. In designing DLL's, however, one of the main problems is the phase comparator. Unlike the situation in synchronization circuits for telecommunications, the phase comparator must distinguish a positive (leading) from a negative (lagging) delay between the relevant features of the two waveforms to be compared. Several solutions have been proposed for this problem [1,2]. This design is proposed as a robust alternative when only one frequency of operation is of interest.

The circuit lends itself, to be used as a kernel in a number of applications, such as clock pulse alignment and de-skewing, time interval generation for serialization and de-serialization schemes in telecommunications, and time-to-digital conversion. Direct time-to-digital conversion, as opposed to time-to-amplitude conversion followed by a multichannel analyzer, requires excessive clock speeds if sub-nanosecond time resolutions are to be achieved. An improvement can be made if the period of the clock is finely divided into smaller intervals and then edges, not pulses, are counted. In this work

a tapped, electrically controllable delay line was used to obtain edges delayed by exactly 1/32 of the clock period. Precise spacing of the successive pulse edges was achieved by means of a feedback scheme, forming a delay-locked loop (DLL).

II. DELAY LOCKED LOOP

An overall block diagram of the DLL circuit is shown in Fig. 1.

Fig. 1 Block diagram of the DLL chip

The tapped delay chain is controlled by a DC voltage generated by the phase detector, the operating principle of which ensures that feedback is always negative. The multiplexer is built along conventional lines, and will not be discussed here. The critical components of the diagram in Fig. 1 are the delay chain and the phase detector.

A. Delay Chain

The delay chain is a modified version of the one used by Arai *et al* [3]. One cell is depicted on Fig. 2.

During the time when the input of the circuit in Fig. 2 is high, the current available to discharge the parasitic capacitance C_1 seen from point B to ground is the current through M5. This in its turn determines the time delay between turning on M2 and turning off M4. It can be readily observed that this variable delay acts on the *trailing* edge of the waveform at the output of the inverter M2-M4. A similar line of thought applies to M6 with respect to the charging rate of the parasitic capacitance C_2 , with the difference that now the gate voltage of M6 controls the delay of the *leading* edge of the waveform at the output of the circuit. If this cell is part of a chain of n similar cells, a pulse delayed by nt with respect to the input appears at the output where t is the delay of the cell represented in Fig. 2. This delay is controlled by the gate voltage of M5 and M6. The range of delay can be controlled by sizing the transistors in the circuit.

Fig. 2 Delay element unit cell.

B. Phase Detector

The causal relationship between the two waveforms to be compared (A and B in Fig. 4) makes it necessary for the phase detector to distinguish between a phase lag of a and a phase lead of $2\pi - a$. This is distinct from the situation in a PLL, as in PLL's the two waveforms whose phase is to be compared are uncorrelated. The P and N pulses needed to drive the charge pump of Fig. 3 are generated by a phase detector based on the Müller C-element. [4]

Fig. 3 Complete phase detector

Fig. 4 shows the relevant idealized waveforms for the complete phase detector circuit. It is readily observed in Fig. 4 that, as long as the A and B pulses overlap, the output of the C-element follows whichever of the inputs, A or B, lags the other. The only condition for this is that the two inputs must overlap.

The addition of some simple logic permits the generation of the P and N signals to control the pump that generates the control voltage V_C for the delay chain.

As implemented, the circuit operates on the falling edge of waveforms A and B. Feedback is negative, as needed: a positive change in V_C decreases the delay. Under lock, P will

stay at 1 and N at 0. V_C only has to change in order to compensate for the charge lost in the holding capacitor C_H through leakage. A very low jitter is thus to be expected.

Fig. 4 Idealized waveforms of the phase detector circuit showing the proportional control.

The DLL circuit was implemented in a $1.2\mu\text{m}$, double-metal, single poly-technology by MOSIS. A 16-element delay cell was built. Care was taken to ensure that the load presented at each tap of the cell was similar. This is guaranteed by a decoder using conventional gate logic. Appropriate termination of the delay chain was achieved by proper sizing of the load from the last cell. A reset-on-power-up circuit was also added in order to provide for proper initialization. This circuit ensures that the chain starts at minimum delay (approximately 18ns), so that the A and B waveforms in Fig. 4 are certain to overlap.

III. TDC Circuit

A. Dual Edge Phase Detector

For the TDC circuit a pair of the Müller C-element based phase detectors are used. Each phase detector separately locks to the leading and falling edges of the reference clock. The dual edge control allows very long delay chains to be constructed without concern for signal dispersion or extinction due to potentially different propagation speeds of the two clock edges. Along with some logic and two charge pumps, this circuit generates, with a minimum number of components, two control voltages V_{C1} and V_{C2} needed to control the delay chain. It can be shown that the two resulting feedback loops, being of first order, are inherently stable. Similar TDC circuits have been previously reported; however, these are based on single-edge control.[3,5,6]

B. TDC Implementation

The simplified block diagram of the TDC circuit is shown in Fig. 5. The critical blocks are the DLL and the dynamic latches. The delay chain shown is a chain of double inverters with a dual phase detector for separately controlling the delay on the leading and the falling edge. In this variation the control voltages V_{C1} and V_{C2} separately connect to the control points on M4 and M5 in the delay element.

The simulation results for the time delay of the delay element unit cell is shown in Fig. 6. The result shown is given for $V_{C1}=V_{C2}$.

Fig. 5 Block diagram of the TDC chip

C. Latching Scheme

Operation of the TDC output latches is shown in Fig. 5. The first set of latches (register) fulfills the function of storing the state of the STOP line along the 32 time intervals into which the clock period is divided. This information must, however be stored until at least the end of the cycle (encoder).

Fig. 6 Simulation of the delay through a unit cell as a function of the control voltage for $V_{c1}=V_{c2}$.

IV. TEST RESULTS FOR THE DLL CIRCUIT

A chip was produced and tests were carried out using a pulse generator and a time interval counter. The loop locked for clock periods between 17.97 and 30.08ns (≈ 33 to 55MHz). Maximum deviation of the measured delay per cell with respect to the expected value was 0.89%. Lock time was 2.5 μ s. Measured jitter using the above setup was ≈ 50 ps. However, the manufacturer quotes 37ps for the inherent jitter of the interval counter. When this is taken into account, a reasonable value for the jitter of the system should be below 35ps.

V. TEST RESULTS FOR TDC CIRCUIT

A demonstration chip was built using a standard 0.8 μ m digital technology, with a single poly-silicon layer and three metal layers. The chip was then tested using a fast pulse generator, a high resolution (<37 ps) time interval counter and a logic analyzer, along with some standard test equipment. Under the

stated conditions, the loop was stable for clock periods between 16.89ns (59.2MHz) and 25.15ns (39.8MHz), corresponding to a time resolution of 0.53ns and 0.79ps respectively. Time jitter, defined as the rms delay deviation from the expected value, was below 80ps throughout the measured range of operation, even when no allowance is made for the time jitter of the experimental setup itself. Differential and integral non-linearity showed values of the same order of magnitude, both staying below one third of a least significant bit throughout the range. Plots of worst case INL and DNL are shown in Fig. 7.

Worst Case DNL And INL

Fig. 7 Plot of TDC Integral and Differential Non-Linearity.

VI. CONCLUSIONS

Loop performance is limited at the high end of the frequency range by the minimum delay achievable within the available the technology, and at the low end by the degree to which current control transistors M4 and M5 can be starved.

If a very long chain is desired, the inevitable asymmetries in the delay times for the leading and the falling edge of the clock pulse (assumed above to be a symmetrical square wave) will eventually lead to pulse extrinction. This difficulty can be circumvented by using a double loop configuration, where one loop controls the leading edge of the delayed pulse and the other the falling edge.

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